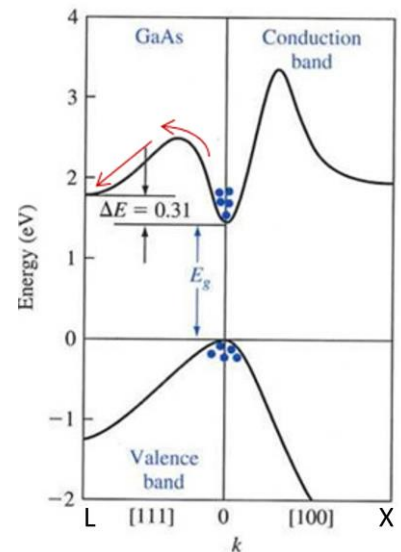


**ECE 3030 Spring 2025****HOMEWORK ASSIGNMENT NO. 3****Due: Monday, February 3<sup>rd</sup> 11:59 pm upload to Carmen 3030 SpeedGrader**

- (10 pt) Using the Fermi function, determine the probability that an energy level is occupied by an electron if the state is above the Fermi level by (a)  $kT$ , (b)  $4kT$ , and (c)  $9kT$ . For (a), what is the probability that the energy level is unoccupied?
- (25 pt) Silicon at  $T = 300\text{ K}$  is doped with arsenic atoms such that the concentration of electrons is  $n_0 = 7 \times 10^{15}\text{ cm}^{-3}$ . (a) Find  $E_c - E_F$ . (b) Determine  $E_F - E_v$ . (c) Using the result in (b), calculate  $p_0$ . (d) Which carrier is the minority carrier? (e) Find  $E_F - E_i$ . For Si, use  $E_g = 1.12\text{ eV}$ ,  $n_i = 1.5 \times 10^{10}\text{ cm}^{-3}$ ,  $N_C = 2.8 \times 10^{19}\text{ cm}^{-3}$  and  $N_V = 1.04 \times 10^{19}\text{ cm}^{-3}$ . Show your work.
- (20pt) Determine the equilibrium electron and hole concentrations in silicon for the following conditions:
  - $T = 300\text{ K}$ ,  $N_d = 10^{15}\text{ cm}^{-3}$ ,  $N_a = 4 \times 10^{15}\text{ cm}^{-3}$
  - $T = 300\text{ K}$ ,  $N_d = 3 \times 10^{16}\text{ cm}^{-3}$ ,  $N_a = 0$
  - $T = 300\text{ K}$ ,  $N_d = N_a = 2 \times 10^{15}\text{ cm}^{-3}$
  - $T = 375\text{ K}$ ,  $N_d = 0$ ,  $N_a = 4 \times 10^{15}\text{ cm}^{-3}$
  - $T = 450\text{ K}$ ,  $N_d = 10^{14}\text{ cm}^{-3}$ ,  $N_a = 0$ .
- (15 pt) (a) Determine the concentration of donor impurity atoms that must be added to a Si crystal so that the Fermi level is  $0.20\text{ eV}$  below the conduction band edge. The Si band gap is  $1.11\text{ eV}$  and  $n_i = 1.5 \times 10^{10}\text{ cm}^{-3}$ , (b) Suppose that the Si crystal already has  $10^{16}\text{ cm}^{-3}$  acceptor impurity concentration. What concentration of donors must be added now to achieve the same result?
- (15 pt) Since the effective mass of electrons in a conduction band decreases with increasing band curvature, comment on the electron effective mass in the  $\Gamma$  valley of GaAs compared with the indirect X or L valleys. How is this effective mass difference reflected in the electron mobility for GaAs vs. the indirect X valley electron mobility in GaP (see Appendix III, S&B.) What would you expect to happen to the conductivity of GaAs if  $\Gamma$ -valley electrons drifting in an electric field were suddenly promoted to the L valley?
- (15 pt) A  $2\text{ cm}$  long piece of Si with cross-sectional area of  $0.1\text{ cm}^2$  is doped with donors at  $10^{15}\text{ cm}^{-3}$  and has a resistance of  $90\text{ ohms}$ . The saturation velocity of electrons in Si is  $10^7\text{ cm/s}$  for fields above  $10^5\text{ V/cm}$ . Calculate the electron drift velocity if we apply a voltage of  $100\text{ V}$  across the piece. What is the current through the piece if we apply a voltage of  $100\text{ V}$  across it? What is the current for  $200\text{ V}$ ? What about  $10^6\text{ V}$ ? Is current still proportional to applied voltage?



**10 Point Bonus:** The maximum intrinsic carrier concentration in a silicon device must be limited to  $5 \times 10^{11}\text{ cm}^{-3}$  thermally stimulated carriers. Assume  $E_g = 1.12\text{ eV}$ . Determine the maximum temperature allowed for the device. (b) Repeat part (a) if the maximum intrinsic carrier concentration is limited to  $5 \times 10^{12}\text{ cm}^{-3}$ . Hint: Trial and error temperatures needed. Show your work.